



Attorney Docket No.:
SP02-260

ITW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor: BELLMAN, et al.

Serial No: 10/722,769

Filing Date: November 26, 2003

Title: METHOD USING MULTI-
COMPONENT COLLOIDAL
ABRASIVES FOR CMP
PROCESSING OF
SEMICONDUCTOR AND
OPTICAL MATERIALS

Group Art Unit: 1765

Examiner: CHEN, Kin Chan

RESPONSE

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESPONSE TO THE EXAMINER'S RESTRICTION REQUIREMENT

In response to the Office Action dated March 3, 2005 in the above-captioned application, please enter the following Amendments and Remarks.

Amendment to the specification begins at page 2 in this paper.

Amendments to the claims begin at page 3 in this paper.

Remarks begin on page 7 in this paper.